Influence of Light Polarization on Photoswitching of Fulgimide Monolayers on surfaces

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Abstract :

The photo isomerization characteristic parameters (photo-stationary states (PSS), cross section σ , quantum yield η) of indolyl fulgimide compounds dispersed in solution are quantitatively compared to those of the same compounds covalently immobilized as a monolayer on a functionalized Si(111) surfaces (see *Advanced Materials* 25, 416 (2013)). The photo isomerization kinetics of fulgimide compounds in solution is monitored using UV-Vis spectroscopy and that of monolayers by in situ *calibrated* FTIR spectroscopy. While the isomeric composition at photo stationary states are very similar in solution and at surfaces, a strong influence of the incident light polarization is found on photo isomerization cross section σ ($\sigma_s \ll \sigma_p < \sigma_{sol}$). Accounting for the local excitation electromagnetic field indicates that the fulgimide groups adopt a preferential tilt angle with respect to the surface normal and that their transition dipole is almost parallel to the surface plane for either C or E/Z isomers. DFT indicates that this orientation corresponds to photochromic groups that are lying in contact with the underlying monolayer. This interaction plausibly explains why the quantum yield of photoisomerization is found nearly twice lower at the surface than in the solution.

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1. Introduction:

Photochromic molecules are molecules capable of changing conformation upon absorption of electromagnetic radiation [1]. This unique property is exploited in many different fields. For instance photochromic molecules were incorporated into polymers [2] [3] or thin films [4] [5] [6] [7] [8] [9] [10] to realize multifunctional layers, in particular to store information [11] [12] [13] or modulate charge transport [14] [15]. Photochromic molecules can also be used in the context of biological systems [16], to structure soft matter with light [10], to control the function of biomaterials [17], or to promote catalytic activity [18]. Immobilization of photochromic molecules on surfaces [19] [20] [21] [22] [23] [24] [25] [26] [27], very often on gold, or self-assembled as Langmuir-Blodgett (LB) layers [28] is a further approach to control wettability of surfaces with external light [29], which is crucial in microfluidics, or to tailor surface conductance [30] [31] [32] [33] [34] and surface work function.[35] [36] [37] [38] Photochromic molecules can be also adsorbed on nanoparticles to control their properties [39].

On the molecular scale, photo isomerization implies the absorption of a photon by the molecule which promotes the molecule to a Frank-Condon state before the excited electron relaxes to a lower-energy state which brings the photochromic molecules either to its starting state or to another isomeric state [40]. The probability of the latter event corresponds to the quantum yield (η) and it has been established that η depends on chemical substituents and polarity of the solvent in the case of azobenzenes [41] [42] [43] [44], fulgides [45] [46] [47,48] and spiropyrans [49] [50] [51] or diarylethenes [52] [53] dispersed in a solvent. [The behaviour at the surface depends strongly on the architecture of the assembly \(for a review at metallic surfaces see Ref. \[40\]\).](#) When the photoswitching molecules are in direct contact with the substrate, the photoswitching occurs but seems very slow [{Comstock, 2007 #758}](#) [{Safiei, 2012 #752}](#). This may partly due to steric hindrance, [chemical and/or electronic coupling with](#)

the substrate. This motivated studies aiming at increasing the free volume around photochromic compounds [56] [19] [57,58] and to reduce the electronic coupling with the substrate [59] [33] [31] using chemical spacers or a semimetal as substrate {Nickel, 2017 #1352}. In such constructs the photo kinetics of photo isomerization of photochromic molecules, characterized by its effective cross section (σ), may be as fast as in solution. This has been demonstrated with azobenzene derivatives {Wagner, 2009 #1473} {Kreikiehn, 2015 #1286} {Moldt, 2016 #1409}. However σ is yet found to be much smaller than in solution for fulgimides tethered on an organic monolayer on silicon {Schulze, 2015 #1314} or spirocyan {Nickel, 2017 #1352} evaporated on Bi(111), which minimizes electronic coupling. ~~Lateral steric effects, mechanical and/or electronic coupling with the substrate are frequently invoked to explain the different behaviour at surfaces, and this motivated various strategies to increase the free volume around photochromic compounds [56] [19] [57,58] or to reduce the electronic coupling with the substrate [59] [33] [31] using chemical spacers or using semimetals with a small density of states at Fermi level [26]. In spite of significant improvements, when the photo isomerization cross section (σ) is determined [60] [26] [61] [63], σ is generally smaller than the value measured for the same photochromic molecule dispersed in a solvent and the behaviour at the surface depends on the architecture of the assembly (for a review at metallic surfaces see Ref. [40]).~~ Therefore other effects need to be considered and substituent effects seem too small to account for above mentioned differences between the kinetics of the photoswitching at surfaces and in solution. One key physical effect that has been largely ignored in the past is the influence of the local excitation electromagnetic field $\vec{E}_{loc}$ although it is well known that photochemistry is strongly influenced by the presence of a substrate [62]. Such a knowledge appears however indispensable to discuss the influence of local chemical environment on the photoisomerization cross sections.

In this work we have investigated the photoswitching properties of fulgimide compounds because they present the key advantage of a very good thermal stability and a large quantum yield [45]. **Scheme 1** displays the structure of the fulgimide isomers and solid arrows indicate optical transitions under visible ($\lambda \sim 525$ nm) and UV light ($\lambda \sim 365$ nm). Both wavelengths refer to the main absorption band of the respective isomers. Visible irradiation promotes ring opening which transforms the closed form (C) into the open form (E). UV irradiation leads to the back formation of the C-isomer but also of another open form (Z-isomer). Amino-fulgimide may be immobilized as a monolayer on a surface (see **scheme 2**) [22]. The photo isomerization kinetics are monitored in solution using UV-Vis spectroscopy and at surfaces using in situ *calibrated* FTIR spectroscopy. A new experimental protocol has been developed with respect to Ref. [22] in order to determine the photo isomerization cross section (σ) and the composition of the surface at the photo-stationary states (PSS) with high precision. In the case of fulgimide MLs, σ is investigated as a function of the incident light polarization and the fulgimide surface density. Results are discussed within the framework of a molecular model and the properties of the *local* electromagnetic field.

2. Experimental:

All chemicals used for surface modification (purchased from Aldrich) were of the highest available purity and used as received. Indolyl fulgimide compounds substituted with an ethyl-amino linker were synthesized as detailed in reference [21]. For silicon etching, electronic-grade chemicals (Carlo Erba, RSE) were used. ATR-FTIR silicon prisms were cut from double-side polished (FZ-purified, 800 Ω .cm) n-type Si(111) wafers with 0.2° miscut angle along the $[11\bar{2}]$ direction (Sil'tronix, France). For AFM observations one-side polished (CZ purified, 1-10 Ω .cm, with a similar miscut) were used. The silicon (111) surface was first treated by anisotropic etching in oxygen-free 40% NH_4F solution as reported before to obtain

clean H-terminated Si(111) surfaces with wide and atomically flat terraces separated by bilayer-high steps (3.1 Å). [63,64]

Monolayer characterizations: FTIR characterizations were performed in ATR geometry with an Equinox 55 spectrometer (Bruker, Germany) equipped with a liquid-nitrogen cooled Mercury-Cadmium Telluride photovoltaic detector. The ATR samples (thickness 500-550 μm) were shaped as prisms with two opposite sides bevelled at ~ 45°. Their length (~15 mm, for ca 30 internal reflections) was chosen to obtain wide range FTIR spectra (1000– 4000 cm⁻¹). Measurements were carried out in a N₂-purged ATR chamber to minimize the contribution of H₂O vapour and CO₂ absorption bands. Spectra were recorded in s- and p-polarization.

In situ monitoring of photoswitching:

In the case of monolayers, photo switching was monitored by in situ FTIR spectroscopy using a specifically home-designed optical experimental setup installed within the custom chamber of the IR spectrophotometer (see scheme in **supplementary information, section S1**). Both sides of the sample were irradiated with a quasi-parallel beam using LEDs (UV: 365 nm, 35.9 mW/cm²; Vis: 525 nm, 51.5 mW/cm²) and cylindrical lenses. Neutral filters were used to adjust the photon flux. For most of the experiments, a 45° incidence angle is used. Polarizers were added for experiments with p-polarized light. For experiments with s-polarized light, it has been found more reliable to work at normal incidence rather than using polarizers, in order to ensure the absence of any residual electromagnetic-field component normal to the surface. A computer controlled shutter allowed for irradiating the sample with short light pulses (few ms) at the very initial stages of the photo-switching and longer ones (1-100 s) at the subsequent stages to control the photon dose. Photon fluxes were calibrated in each configuration with a photodiode to determine the photon dose during light pulses. The

nominal photon flux (in the absence of neutral filters and polarizers) was $6.6 \cdot 10^{16}$ photons $\text{cm}^{-2} \text{s}^{-1}$ and $1.4 \cdot 10^{17}$ photons $\text{cm}^{-2} \text{s}^{-1}$ for UV and visible light, respectively. FTIR spectra (150 scans, resolution 4 cm^{-1}) were recorded between light pulses, i.e., in the dark where the system is stable. This procedure allows for recording FTIR spectra corresponding to controlled photon dose for an accurate determination of the photokinetics.

Photo switching in solution was characterized with a similar approach using in situ UV-Vis spectroscopy. 20 μM of either E- or C-fulgimide were dissolved in acetonitrile. A simplified optical setup was installed in the spectrophotometer (Agilent Technologies, Cary 50) to monitor the process. The nominal photon flux (in the absence of neutral filters and polarizers) was $3.3 \cdot 10^{16}$ photons $\text{cm}^{-2} \text{s}^{-1}$ and $2.2 \cdot 10^{17}$ photons $\text{cm}^{-2} \text{s}^{-1}$ for UV and visible light, respectively. A similar protocol, recording UV-Vis spectra between light pulses, was used.

Preparation of fulgimide monolayers with variable surface densities: Pure C- and E-fulgimide were synthesized as reported in ref. [21] and immobilized on the silicon surface using the multistep protocol described in **Scheme 2**. The primer COOH-terminated monolayer (step 1) was grafted by photochemical reaction (wavelength 312 nm) between the H-terminated surface and neat undecylenic acid as detailed in Ref. [65]. The “activation” of the carboxylic groups (step 2) was performed in MES buffer (pH=5, 15°C, under Ar bubbling) containing N-Hydroxysuccinimide (HOSuc, 100 mM and 1-ethyl-3-(3-dimethylaminopropyl)-carbodiimide (EDC, 100 mM). The reaction time was 1h. The samples were then rinsed successively (10 min, 40°C, pH = 5) in 0.1M NaH_2PO_4 , 0.01M NaH_2PO_4 , in ultra-pure water and blown dry using an Ar stream. The coupling of the fulgimide (step 3) was conducted in an acetonitrile solution containing 5 mM of fulgimide (2h at room temperature, in the dark). More details are given in Ref. [22]. To vary the photochromic molecule density, step 3

(**scheme 2**) was also conducted in an acetonitrile solution containing amino-fulgimide and ethylamine. An excess of fulgimide was used to account for the slower coupling rate of fulgimides (4000 s^{-1}) with respect to that of ethylamine (200 s^{-1}) (measured from complementary *in situ* FTIR measurements, data not shown). Ethylamine /fulgimide ratios of 0.17, 0.26, 0.33 and 0.66 were used.

Full range FTIR spectra recorded at the different steps of the preparation of the fulgimide MLs are given in supplementary information (**section S2**). They are perfectly consistent with previous results [22]. Also explained in supplementary information (**section S2**) all samples studied in this work present a contamination level that is below 0.1 equivalent monolayer. The chemical composition of all surfaces was quantitatively determined from careful calibration of the $\nu\text{C=O}$ band at 1715 cm^{-1} related to COOH groups [65] [66]. More details are given in **supplementary information, section S2. e**

Computational methods:

The geometries of the fulgimide compound in the C, E and Z forms were fully optimized using the Becke-3-Lee–Yang–Parr (B3LYP) exchange functional [67] with the 6-311+G(d,p) basis set, in vacuum, as implemented in the Gaussian 09 software package [68]. The absence of negative frequencies was checked to ensure true minima for all geometries. Frank-Condon energy transitions and corresponding transition dipole moments were calculated using the time-dependent DFT formalism (TD-DFT) with the same functional and basis set. As explained in the text, the functionalized monolayer on Si(111) surface was sketched without minimization. The DFT cell consists of alkylamide molecules as spacer chains (optimized separately) along a $3.84 \times 6.65\text{ \AA}$ rectangular 2D-assembly and one fulgimide-terminated chain.

3. Results:

3.1 Photoswitching in solution vs. at surfaces:

Figure 1a shows series of UV-Vis spectra of a 20 μ M C-solution (in acetonitrile) irradiated with 525 nm light at nominal photon flux. The red line is the initial spectrum (C-form) and the blue line is the last spectrum of the experiment. The main absorption band around 530 nm (red line), and that around 350 nm (blue line) are in perfect agreement with those reported in the literature for the C- and E-isomers, respectively [47]. All intermediate spectra (grey lines) can be accounted for by a linear combination of the spectrum of the initial pure C-solution and that of the final solution. The relative weight of the coefficients in this combination provides the *relative* advancement $0 < \alpha < 1$ of the photo isomerization reaction, as plotted in panel (b), (black squares, left y-scale), for the first Vis illumination. Keeping the pure C-solution as the reference state, the advancement of the backward photoisomerization under UV is also plotted in panel (b) (open squares). The composition along the photoconversion was simply determined by fitting each intermediate spectrum with a linear combination of the spectra of solutions composed of pure E- and C-isomers of known concentrations (full line, right scale in panel b).

Figure 1c displays narrow range FTIR spectra recorded during the photo switching of an initially pure and dense C-monolayer. The surface density of immobilized fulgimide was determined as explained in **section S2 of the supplementary information**. It is 1.6 C-isomers/nm² for this sample. The initial spectrum (red line) presents two main IR bands at 1698 cm⁻¹ and 1758 cm⁻¹ assigned to asymmetric and symmetric ν C=O stretching modes of maleimide groups. Upon visible illumination (525 nm) these two bands progressively shift towards high frequency and their intensity varies. At the end of the experiment (blue line), the positions of the two bands are 1689 cm⁻¹ and 1738 cm⁻¹, which is very close to the positions measured for a pure E-surface (1690 cm⁻¹ and 1739 cm⁻¹). All the above observations are in

perfect accordance with previous work [21] [22]. The advancement α of the photoisomerization reaction was determined from differential spectra (see inset of panel c), taking as the reference spectrum that of the initial C-terminated surface: the blue solid line in the inset represents the difference between the blue and red lines shown in the main frame of panel (c). Within this representation, all the intermediate spectra (grey lines) are precisely proportional to the final difference, which straightforwardly provides α for the first Vis irradiation (black squares in panels (d)). Open squares correspond to α during the subsequent UV irradiation period, keeping the initial C-surface as the reference surface. To be quantitative, α was transformed into a number of switched isomers, which is given by the right y-scale in panels (b) and (d). It was done using a specific calibration of the vCO bands of the C and E isomers.

Comparison of panels (b) and (d) in **Fig. 1** immediately points out that in both cases a large amount C-isomers have switched under visible irradiation but that the subsequent UV illumination does not fully restores all the initial C-forms (**Fig. 1b**, symbols). In solution, the first isomerization under Vis is completed within ca 10s with 100% of the C isomers transformed into E forms. The subsequent UV illumination restores 77% of the initial C isomers. At the surface, using a similar photon flux, it takes 100 s under Vis illumination to reach a quasi-steady-state corresponding to the switching of only 87% of the initial C-isomers. The back isomerization under UV light is also slower and less efficient –in terms of back conversion yield– since it restores only 61% of the switched C-isomers. Reaching PSS under UV is possible but requires longer exposure times [22]. This also leads to some photo-degradation of the monolayer. In the following we only present experiments corresponding to short illumination times, leading to incomplete photoconversion.

The data in **Fig. 1** may be replotted as a function of the photon dose p , as justified in supplementary information (**Fig. S5**) to determine the photo isomerization cross section (σ)

and the isomeric compositions at the photo-stationary state (PSS) as it is explained in the Appendix. It is found that σ is approximately constant in the initial stages of the photochromic reaction but then decays above a critical photon dose p^* (see **Fig. A1**). In other words only a *fraction* of the monolayer reacts upon illumination according to a single exponential law with a well-defined value of the cross section σ . In the following we only discuss this value of σ . The decay of σ above p^* will be the subject of a separate article. Notice that the same analysis gives a single exponential law for the complete photoisomerization of C-isomers dissolved in acetonitrile (under Vis light). Under UV, σ decays (by 20%) for high-enough photon doses.

3.2 Isomeric composition at PSS

Panel (a) of **figure 2** presents the evolution of the isomeric composition upon consecutive UV/Vis illumination cycles, starting from a dense E-surface ($1.8 \text{ E-isomers/nm}^2$). About 50% of the monolayer is switched under each light exposure. Panel (b) of **Fig. 2** gives the surface composition at PSS_{UV} (left bar) and PSS_{Vis} (right bar) for each cycle, determined as explained in the Appendix. The composition is given as (C) and (E/Z) surface densities because E- and Z-forms cannot be discriminated by FTIR. The data analysis according to the procedure in the Appendix also yields the cross-section values (σ_{UV} and σ_{Vis}). **Fig. S6** supports this analysis since the resulting σ_{UV} and σ_{Vis} keep the same values over the successive illumination cycles.

Overall the isomeric compositions at PSS appear rather stable upon successive UV/Vis irradiation cycles. A slight enrichment of the surface in C-isomers is noticeable at PSS_{UV} after 6 irradiation cycles. The same trend is observed for PSS_{Vis}. The isomeric compositions at PSS_{Vis} and PSS_{UV} in solution and at surfaces with various densities of immobilized fulgimides are compared in **Figure 3**. In each case the left bar provides PSS_{Vis} and the right one PSS_{UV} after the first visible and the subsequent UV irradiation, starting from a pure C-solution or a

pure C-monolayer. The isomeric compositions at PSSs are also summarized in **Table 1**. One may notice that the PSS_{UV} composition in solution departs from 100% C. Indeed, the presence of a significant proportion of open forms at PSS_{UV} confirms that an additional reaction C → E must be taken into account under UV in **Scheme 1** since the C-isomer presents an absorption band around 350 nm in **Fig. 1a**. For a relevant comparison of the PSSs in solution and at surfaces we consider monolayers with less than $D^* \sim 0.9$ isomers/nm² because steric hindrance may be neglected. Steric hindrance is expected for denser monolayers [22]. With this precaution, **Table 1** shows that the PSS_{vis} is equal in solution and at the surface and that the PSS_{UV} is somewhat richer in E/Z isomers at the surface than in the solution.

3.3 Photokinetics at surfaces

The results of **Figure 4** have been obtained on a sample with an initial isomer density of 1.6 E-isomers/nm². After a few incomplete photoswitching cycles like in **Fig. 2**, the starting surface consists of C and (E+Z) isomers. Therefore, $\ln\left(\frac{[C_{PSS}]-[C]}{[C_{PSS}]-[C_{start}]}\right)$ and $\ln\left(\frac{[E_{PSS}]-[E]}{[E_{PSS}]-[E_{start}]}\right)$ have been plotted as a function of the photon dose p . Here [C] and [E] designate the surface concentration of closed C and open (E+Z) isomers and the suffix refers to the starting surface and surface at PSS. Data analysis indicates that the total number of isomers is constant over successive illumination cycles. As justified in the Appendix, data (symbols in **Fig. 4**) may be fitted to a single exponential kinetics (straight dashed lines) up to a critical photon dose p^* (indicated by the vertical bars in the figures). The photo isomerization cross section σ is the inverse value of the straight-line slope. Above p^* , whose value depends on photon energy and light polarization, the process no longer follows a simple exponential law (slow decay of σ as in **Fig. A1b,d**).

For a given monolayer, the cross section σ was measured for s- and p-polarization of the excitation light (red and blue open squares respectively) and compared to that obtained

with *non-polarized* light (black open squares). The different σ values are reported in the left three blocks of **Table 2**. The right block of **Table 2** gives also the σ -values measured for isomers dispersed in acetonitrile. In solution, the absorption cross section can conveniently be measured and the isomerization quantum yield η is simply determined as the ratio of σ to σ_{abs} . According to **Table 2** the magnitude of σ follows the trend s-pol (surface) < p-pol (surface) < solution for a given wavelength and $\sigma_{\text{UV}} > \sigma_{\text{Vis}}$ in all conditions. Complementary experiments (see **Table S1**) indicate that σ is quasi-independent of the isomer surface density, suggesting that this parameter is well representative of the photo isomerization of the fraction of photochromic molecules that switch from one configuration to the other one without any specific (e.g., steric) limitation. The σ -values measured in solution are close to those reported previously ($\sigma_{\text{UV}} = 5 \cdot 10^{-18} \text{ cm}^2$ and $\sigma_{\text{Vis}} = 2 \cdot 10^{-18} \text{ cm}^2$ [70]). The differences may come from the substituent and/or the solvent which are different in our work. Concerning the cross sections measured at the surface, our values with non-polarized light are also in fair agreement, within a factor 2-4, with recently published data ($\sigma_{\text{UV}} = 2.3 \cdot 10^{-18} / \text{cm}^2$ and $\sigma_{\text{Vis}} 1.2 \cdot 10^{-18} / \text{cm}^2$) for fulgimides immobilized on a silicon surface [71].

4. Discussion

All in all, the data in **Table 2** are consistent with past literature and confirm that the experimental values of σ_{UV} or σ_{Vis} are smaller at the surface than in solution. To the best of our knowledge, the light polarization dependence of the photoswitching efficiency is quantitatively investigated for the first time. The main purpose of this section is therefore to discuss the photo isomerization cross section σ and particularly its dependence on light polarization at surfaces. The quantum yield is also discussed.

As recalled in the introduction, photo isomerization implies that absorption of a photon by the molecule brings it into an excited transition state before it relaxes either in its

initial state or into another isomeric state with a probability η (quantum yield). Therefore, the photo isomerization cross section of a molecule may be written:

$$\sigma = \eta \sigma_{abs} \quad (1)$$

The absorbance cross section σ_{abs} is proportional to:

$$J = \frac{1}{N} \int_{\Omega_{min}}^{\Omega_{max}} |\vec{E}_{loc} \cdot \vec{P}|^2 d\Omega \quad (2)$$

This integral outlines that the absorption of a photon by a photochromic molecule does depend on the alignment between the local electric field $\vec{E}_{loc}$ and the transition dipole $\vec{P}$ of the molecule.

In solution $\vec{P}$ is randomly oriented, $\Omega_{min} = 0$, $\Omega_{max} = 4\pi$ and $N = 4\pi$ and $E_{loc}^2 = \frac{1}{n} \left(\frac{n^2+2}{3} \right)^2 E_{vac}^2$ [72], with E_{vac} the electric field in vacuum and n the refractive index of the solvent ($n = 1.34$ for acetonitrile). Therefore $J = 1/3 P^2 E_{loc}^2 = 1.27 P^2 E_{vac}^2$. In the case of a monolayer of photochromic molecules immobilized on a substrate, one must take into account two points: (i) $\vec{E}_{loc}$ is affected by the close proximity of the substrate and (ii) $\vec{P}$ may be constrained in certain directions of space. To the best of our knowledge, these considerations were not discussed at surfaces in literature although light polarization is known to induce reorientation of azobenzene in a polymer matrix [28,73].

4.1 Photo isomerization cross section at surfaces:

Figure 5 defines the relative orientation of $\vec{E}_{loc}$ and $\vec{P}$. $\vec{E}_{loc}$ is set within the (y,z) plane at an angle α with respect to the surface normal (direction z) and the orientation of $\vec{P}$ is given by its angle β with respect to surface normal and the azimuth angle γ of its projection on (x,y) plane. Two extreme hypotheses are considered.

Within the first one, the immobilized fulgimides adopt a random orientation with respect to surface normal. In this case, $0 \leq \beta \leq \pi/2$, $0 \leq \gamma \leq 2\pi$, $\Omega_{\min} = 0$, $\Omega_{\max} = 2\pi$ and $N = 2\pi$ in Eq. (2). The integral J therefore reduces to $J = 1/3 P^2 |E_{loc}|^2$, independently of α , i.e., the polarization of the illumination. In that case the ratio $\frac{\sigma_s}{\sigma_p} = \frac{|E_s|^2}{|E_p^\parallel|^2 + |E_p^\perp|^2}$ and it depends only on the illumination energy. Under UV light, $\frac{\sigma_s}{\sigma_p}$ would be ~ 0.12 and under Vis light $\frac{\sigma_s}{\sigma_p}$ would be ~ 0.04 . These values are sufficiently different from the experimental ones ($\sim 0.23 \pm 0.05$ for either UV or Vis illumination, see **Table 2**) to rule out this hypothesis.

Within the second hypothesis, the fulgimide are constrained by their environment and adopt a specific orientation. In this second case an angle β in **Fig. 5** may probably be defined but the angle γ is likely to be random between 0 and 2π . Therefore, J reduces to $\left[\frac{1}{2} \sin^2(\beta) \sin^2(\alpha) + \cos^2(\beta) \cos^2(\alpha) \right] P^2 E_{loc}^2$, where α depends on light polarization and $\vec{E}_{loc}$ is given by **Eqs. (S1-S2)** in the supplementary information [74]. In s-pol conditions, $\alpha = \pi/2$ and $J = \frac{1}{2} \sin^2(\beta) |E_s|^2$ with E_s given by (**Eq. S1**). At the incidence $\theta = 45^\circ$ and with p-pol light, $J = P^2 \left(\frac{1}{2} \sin^2(\beta) |E_p^\parallel|^2 + \cos^2(\beta) |E_p^\perp|^2 \right)$, with $\vec{E}_p^\parallel$ and $\vec{E}_p^\perp$ the components of $\vec{E}_{loc}$ parallel and perpendicular to the surface, which expressions are given in **section S5** in the supplementary information. For the numerical evaluation, the dielectric constant of silicon was taken from Ref. [75] at the relevant wavelength. At the silicon/air interface these equations yield $|E_p^\parallel|^2 \ll |E_p^\perp|^2$. Assuming that the isomerization quantum yield η is independent on light polarization, the ratio $\frac{\sigma_s}{\sigma_p}$ can be computed as a function of β either to UV or Vis illumination. By comparing to the experimental ratio, one obtains the value of β corresponding to the UV and Vis transition dipoles. For the UV excitation, β is found to be $\sim 74^\circ$ and for the Vis excitation, $\beta \sim 64^\circ$. In either case, $\vec{P}$ appears close to the surface plane.

DFT and TD-DFT calculations were performed with the Gaussian 09 package with the B3LYP functional and the 6-311+G(d,p) basis set in vacuum, and provided the minimized geometries, relative energies and Franck-Condon electronic transition energies for the three isomers C, E and Z (**Fig. 6a**). Given the orientation of $\vec{P}$ of the two relevant isomeric forms C and E as derived from TD-DFT computations, the experimental values of β mean that the C- and E-forms are similarly oriented and are almost lying parallel to the surface plane. This large tilt angle between the direction of the transition moment of the molecules and the surface normal may be accounted for by a rotation around the C-C and C-N bonds of the amide linkage to the monolayer. The configuration of the fulgimide is therefore different from that assumed in Ref. [22] where a nearly upright orientation was postulated because this corresponds to the equilibrium configuration of the isolated molecule (the fulgimide molecule coupled to the carboxylic acid).

According to **Fig. 6**, the experimental angle $\beta = 74^\circ$ implies that the fulgimide groups must be almost parallel to the surface plane. To check the feasibility of this configuration, the grafted monolayer was modelled with alkylamide molecules (optimized separately) assembled along a $3.84 \times 6.65 \text{ \AA}$ rectangular mesh (see atomic model in **Fig. 7a**). This corresponds to a density of 3.9 chains grafted per nm^2 which is the maximum packing density on a Si(111) surface [69]. The DFT cell is limited to 3×3 chains and a photochromic molecule in its C-form is attached on one site located at the perimeter of the rectangular cell. It is tilted such as to bring its transition dipole moment at an angle $\beta = 74^\circ$ with respect to the surface normal. The model shown in **Figs. 7b-c** corresponds to a situation where a vacancy is assumed to be present in the center of the DFT cell. In the side view (**Fig. 7c**), one clearly sees that the photochromic molecule is partially embedded inside the molecular carpet. Though these structures are not an optimized configuration of the supramolecular assembly, which is beyond the DFT computations performed here, such a tilted configuration is energetically

affordable and a similar energy is found if the C-fulgimide is anchored on any other sites at the perimeter of the DFT cell. Similar energies are also found with a tilted E-fulgimide instead of a C-fulgimide. As to be expected, however, the energy barrier becomes too large for either a C- or a E-fulgimide without the vacancy at the center of the 3 x 3 cell. This shows that the vacancies in the grafted monolayer play a crucial role.

The model presented in **Fig. 7** closely corresponds to real molecular surface concentration since the DFT cell is equivalent to ~ 3 chains / nm^2 and ~ 1 fulgimide / nm^2 whereas a dilute fulgimide monolayer is composed of 2.8 chains grafted per nm^2 and 0.9 C-fulgimide / nm^2 . Experimentally, there are enough vacancies ($1.1 / \text{nm}^2$) to accommodate all the immobilized photochromic molecules with a tilt compatible with experimental results. Given the influence of the light polarization on the cross section, we therefore postulate that the majority of immobilized fulgimides must adopt such a tilted configuration, without excluding that a small fraction of the photochromic molecules may adopt a non-tilted configuration.

A tilted molecular configuration was not to be expected and appears counter intuitive. Explain its origin would require dedicated supramolecular calculation. Nevertheless, based on above observations, one may suspect that this configuration comes from strong interactions between the fulgimide and the acid-terminated monolayer *prior* to the formation of the amide bond. In fact a large angle β is already measured after immobilization since the cross sections $\sigma_{s,p}$ are constant from the very first photoswitching cycle for either pure C- or E-fulgimide monolayers. This tilted configuration may be maintained upon successive photoswitching because there is a small difference between the β values for the UV and Vis transition. This strongly suggests that the photochromic reaction mainly involves the C $\rightarrow$ E and E $\rightarrow$ C photoisomerization, with a negligible contribution of the Z form because the direction of $\vec{P}$ for

the Z form is significantly rotated, with regard to the N-C bond of the alkylamide chain, see **Fig. 6c**).

4.2 Isomerization quantum yield at surfaces:

The quantitative determination of the optical absorption of a monolayer on an absorbing substrate like silicon is difficult and an absolute value of the isomerization quantum yield η (Eq. 1) appears out of reach here. However, the determination of J in different environments and that of the angle β allows for estimating the ratio of the isomerization quantum yield in solution with that at the surface.

On the basis of Eq. (1) and the above expressions of σ , it comes (for experiments at 45° incidence angle in p polarization and normal incidence in s polarization):

$$\frac{\sigma_p}{\sigma_{sol}} = 3n \left(\frac{3}{n^2+2} \right)^2 \left(\frac{1}{2} \sin^2(\beta) \left| \frac{\sqrt{2}\sqrt{\epsilon_{Si}-1/2}}{\epsilon_{Si}/\sqrt{2}+\sqrt{\epsilon_{Si}-1/2}} \right|^2 + \cos^2(\beta) \left| \frac{\epsilon_{Si}}{\epsilon_{Si}/\sqrt{2}+\sqrt{\epsilon_{Si}-1/2}} \right|^2 \right) \frac{\eta_{surf}}{\eta_{sol}} \quad (3a)$$

$$\text{and: } \frac{\sigma_s}{\sigma_{sol}} = 6n \left(\frac{3}{n^2+2} \right)^2 \sin^2 \beta \left| \frac{1}{1+\sqrt{\epsilon_{Si}}} \right|^2 \frac{\eta_{surf}}{\eta_{sol}}. \quad (3b)$$

Numerical evaluation of these expressions using the above β values allows a comparison with the experimental values given in **Table 2**. For the UV transition, the computed values are $\frac{\sigma_p}{\sigma_{sol}} = 0.32 \frac{\eta_{surf}}{\eta_{sol}}$ and $\frac{\sigma_s}{\sigma_{sol}} = 0.07 \frac{\eta_{surf}}{\eta_{sol}}$, to be compared with the experimental values $\frac{\sigma_p}{\sigma_{sol}} = 0.18$ and $\frac{\sigma_s}{\sigma_{sol}} = 0.04$. In either case, one finds $\frac{\eta_{surf}}{\eta_{sol}} \approx 0.55$. Similarly, for the Vis transition, the computed values are $\frac{\sigma_p}{\sigma_{sol}} = 0.66 \frac{\eta_{surf}}{\eta_{sol}}$ and $\frac{\sigma_s}{\sigma_{sol}} = 0.15 \frac{\eta_{surf}}{\eta_{sol}}$, to be compared with the experimental values $\frac{\sigma_p}{\sigma_{sol}} = 0.37$ and $\frac{\sigma_s}{\sigma_{sol}} = 0.08$. Once again, in either case, one finds $\frac{\eta_{surf}}{\eta_{sol}} \approx 0.55$. Therefore, within the framework of this quantitative analysis, the isomerization quantum yield is found to be independent on light

polarization, which appears reasonable since η is expected to depend mostly on the properties of the transition state and the coupling of the molecule to its environment, both independent on the photon field. For both the UV and Vis transitions, the $\frac{\eta_{surf}}{\eta_{sol}}$ ratio is found to exhibit nearly the same value of 0.55, which can be paralleled to the closely similar configuration of C and E isomers at the surface. It corresponds to an isomerization quantum yield about twice less efficient at the surface than in solution.

The origin of this difference cannot be sought for in terms of local electric field (already taken into account in the above analysis), steric effect between neighbour molecules (since the experimental cross sections do not significantly depend on the surface molecule concentration), or electronic interaction with the substrate (shielded by the molecular layer grafted at the surface). Therefore, we tentatively assign the loss of efficiency of the isomerization at surfaces to the interaction of fulgimide molecules with the surface molecular layer grafted on silicon, which makes them adopt the tilted configuration determined in Section 4.1.

5. Conclusion

In conclusion, the present results demonstrate that when photochromic molecules are immobilized at a surface in a well-controlled configuration, a quantitative analysis of the photoswitching kinetics allows for obtaining a detailed picture of the system at the molecular level. In the particular case of indolyl fulgimide compounds covalently anchored on functionalized Si(111) surfaces the data above show that the photoisomerization remains efficient and reversible and that the photo stationary compositions are close to those found in solution provided steric hindrance is avoided by limiting the surface density of immobilized photochromic molecules, here below 0.9 isomers / nm².

However, from a dynamic view point, surface photokinetics strongly depart from that in solution. The photoisomerization cross sections measured at the surface are much smaller than in solution. In addition, the photokinetics is no longer following a pure first order law. Only a fraction of the photochromic molecules switches with a constant photoisomerization cross section σ . Above a critical threshold, σ continuously decreases with increasing photon dose. The initial σ is representative of the isomers which can freely react upon light absorption and measurements under s- and p-polarized light indicate that the transition dipole of the switching isomers is almost lying in the surface plane, a configuration which corresponds to fulgimides partially embedded in the underlying monolayer. Noteworthy, the open (E) and closed (C) forms exhibit similar configuration. This configuration is likely at the origin of the reduced value of the isomerization quantum yield η which can be derived when comparing experimental photo-isomerization cross sections recorded for “freely” switchable molecules at the surface with those measured in solution.

Appendix

It is worth recalling that typical photochromic reactions $A \leftrightarrow B$ follow the general photokinetic differential equations [76] involving concentrations of all isomers, their related absorption coefficients, thermal reaction rates and photochromic quantum yields corresponding to $A \rightarrow B$ and $B \rightarrow A$ reactions. In the general case and in absence of any approximation, these differential equations show nonlinear terms (known as photokinetic factors) preventing any analytical solution. Nevertheless, in the case of the present fulgimide molecule, thermal reaction rates can be neglected and concentrations are extremely low: absorbance values of our samples at the irradiation wavelengths are smaller than 0.1 in solution and 0.001 at the surface, especially for surfaces functionalized with a (diluted) monolayer of photo-active

molecules. Consequently, photochromic differential equations linearization gives simple first order photokinetics.

However, when photoswitching strongly deviates from a pure exponential law, it appears difficult to make a quantitative comparison between different configurations. To this end, a procedure described below was used to determine the isomeric composition at PSS and the isomerization cross section σ from *partial* photoconversion experiments.

Figure A1 is an example of such a full data analysis. In top panels the solid black lines are plots of the advancement of the Vis and then UV isomerization processes of an initially pure C monolayer after calibration of the y-scale. Data are plotted as function of the logarithm of the photon dose p . The relevance of this plot is justified by **Fig. S5**. The calibration of the y-scale was explained for **Fig. 1**. The derivative of the plots (blue crosses) is empirically fitted to a Voigt function (red line); integration of the Voigt function gives the expected advancement of the photo isomerization, which obviously superimposes the solid black line but also extends it at photon doses for which photochromism was not measured (black dashed line). Such an extrapolation yields the isomeric composition at PSS. This analysis immediately captures that photoconversion was (voluntary made) incomplete, because p was too small to reach the PSSs. This also evidences that a fraction of the C-isomers remains blocked (the monolayer density is $1.6 / \text{nm}^2$ which is above the maximum packing density of isomers in 2D). Panel (b) of **Fig. A1**, is a plot of the cross section which is obtained as $\sigma = \frac{1}{[C(p)]} \frac{\partial [C(p)]}{\partial p}$, with $[C(p)]$ the surface density of switched isomers after illumination with a photon dose p . This plot outlines that σ is constant up to a critical photon dose p^* (regime featured by grey shaded regions) above which a progressive decrease of σ is observed. The *initial* σ (i.e., for $p < p^*$) is accurately obtained by replotting the data as in **Fig. 4** where $\ln(1 - E/E_{\text{PSS}})$ is plotted against p (PSS is the above determined value). Linear regression restricted to $p < p^*$ yields σ with no ambiguity.

The back photo isomerization (panels c and d) was analysed by the same method. However, it is important to note that the situation under UV irradiation is intrinsically more complicated because several photoreactions are expected to occur: $E \rightarrow C$, but also $C \rightarrow E$, $E \rightarrow Z$ and $Z \rightarrow E$. As a consequence, the σ_{UV} values do not correspond strictly to the single $E \rightarrow C$ isomerization. In initial stages of UV irradiation, starting from a E-terminated monolayer, and the $E \rightarrow C$ and $E \rightarrow Z$ reactions represent the major pathways. Under prolonged irradiation, the $C \rightarrow E$ and $Z \rightarrow E$ may play an important role in the system evolution. This time-dependent behaviour may be partly responsible for the decrease of σ as a function of UV photon dose, and the lower value of p^* compared to the one determined under visible illumination. However, at low photon doses, the σ_{UV} value can be approximated to be mostly representative of the $E \rightarrow C$ reaction because (i) the $E \leftrightarrow Z$ photoisomerizations play a negligible role (there are only few percent of Z forms in the PSS composition) and (ii) the C form concentration is very low at initial stage.

It should be noted that the procedure above was tested over a large number of experiments and appears robust. The very same behaviour was indeed observed for all photoconversion experiments for all samples, regardless the surface density of the monolayer. In particular, we emphasize that for the stabilization of the fitting procedure, the fitting with the pseudo Voigt function was performed keeping *fixed* the Lorentzian and Gaussian width and a fixed Gaussian/Lorentzian ratio for all experiments.

Fig. A1: Example of data analysis starting for a pure C-monolayer with 1.6 isomers/nm^2 exposed to visible illumination (left column) and then to UV illumination (right column). This analysis corresponds to the data presented in **Fig. 1**: (a) and (c) the black solid and dashed lines correspond to experimental and calculated variations of the number of switched isomers, respectively, as a function of $\log(p)$, with p the photon dose. Blue symbols are the derivative of the black line and the red line is the best fit using a Voigt function; (b) and (d) variations of the numerical cross section as a function of $\log(p)$. Notice the plateau below a critical value p^* (grey shaded regions).

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Tables:

Table 1:

PSS composition given as C / E+Z relative proportions, in solution (acetonitrile) and at surfaces. D is the initial fulgimide concentration at the surface and $D^* \sim 0.9$ isomers/nm² is the density below which no steric hindrance occurs (see text).

	Solution	Surface ($D \leq D^*$)	Surface ($D > D^*$)
Visible (525 nm)	0 / 100	0 / 100	8 / 92
UV (365 nm)	77 / 23 ^{a)}	66 / 34	63/37

a) This composition is in agreement with literature (C/E/Z) = (77/21/2) [22] [48]

Table 2:

Comparison of isomerization cross sections measured at surfaces (left block) and in solution (right block). For the surface light is either non-polarized, p-pol. and s-pol. light and in solution (right block). All cross sections are given in units of 10⁻¹⁸ cm². UV and Vis wavelengths are 365 nm and 525 nm respectively. Note that σ -values at surfaces are quasi-independent of the fulgimide density.

	surface						solution	
Polarization	non-pol.		p-pol.		s-pol.		na	
λ	UV	Vis	UV	Vis	UV	Vis	UV	Vis
σ_{Vis}		0.33 ± 0.01	-	0.40 ± 0.06	-	0.09 ± 0.03	-	1.08 ± 0.04
σ_{UV}	1.30 ± 0.05		1.51 ± 0.11	-	0.35 ± 0.04	-	8.31 ± 0.29	-
$\sigma_{\text{Abs.}}$							30.3	16.4
η							0.27	0.066

Schemes:

Scheme 1:

Molecular structure of indolyl fulgimide isomers. Solid arrows represent the photochromic reactions occurring under visible ($\lambda = 525$ nm) and UV light ($\lambda = 365$ nm). The dashed arrow is accounting for the PSS composition under UV (see text).

Scheme 2:

Schematic description of the multistep protocol used to immobilize fulgimide compounds on Si(111). (a) Alkyl monolayer terminated by carboxylic acid groups prepared according to Ref. [65]; (b) A succinimidyl-ester “activated” surface is obtained by exposure of (a) to a NHS/EDC aqueous solution; (c) Fulgimide monolayer: variable densities of photochromic molecules are obtained by exposing the “activated” surfaces to a mixture of amino-ethyl indolyl fulgimide and ethyl amine in acetonitrile (see experimental details).

Figures:

Figure 1:

Comparison of photochromism in solution (a-b) and at surface (c-d). Initial state is a pure C-solution or a pure C-monolayer. (a) Series of UV-Vis spectra recorded during the Vis illumination of a 20 μM C-isomers solution in acetonitrile. The initial spectrum (red line) is that of the pure C isomers. The blue line is the last spectrum of the experiment and is very close to that of pure E-solution. (b) Time dependence of relative advancement α (left scale), along the first Vis and subsequent UV irradiation periods. (c) Series of narrow FTIR spectra recorded during the Vis illumination of a pure C monolayer, with 1.6 fulgimides/ nm^2 . The initial spectrum (red line) is that of the pure C-terminated surface. Note that the blue line (last spectrum) is close to that of a pure E-terminated surface. (d) Same as (b). In panels (b) and (d), quantitative solution and surface compositions are given by the right y-scale (see text for more explanation). The concentration of isomers in solution and their density on the surface are highlighted with horizontal blue dashed lines in (b) and (d). The vertical dashed line marks the transition from Vis to UV illumination.

Figure 2:

(a) Time dependence of α (left scale) and surface density of E/Z isomers (right scale) during successive UV and Vis partial photoconversion of a nominal pure E monolayer. The initial surface is an E-surface (1.8 E-isomers/nm²). (b) Isomeric composition of the ML at PSSs: for each UV/Vis illumination cycle a pair of bars gives the extrapolated isomeric composition at PSS_{UV} (left bar) and PSS_{Vis} (right bar) of individual switching cycles. The single bar on the left corresponds to the as prepared E-terminated surface.

Figure 3:

Isomeric composition at PSS_{Vis} and PSS_{UV} in solution and at surfaces, starting with a pure C-solution (20 $\mu\text{mol/L}$) or C-monolayer with various densities of photochromic molecules. In each case a pair of bars gives PSS_{Vis} (left bar) and PSS_{UV} (right bar).

Figure 4:

Influence of light polarization on the photoswitching. (a-b) Progression of the reaction during UV (left) and Vis (right) illumination. The surface density of fulgimides ($C + E/Z$) is 1.6 nm^2 . In (a) the starting surface is composed of $1.1 \text{ E-isomers/nm}^2$ and $0.5 \text{ C-isomers/nm}^2$. In (b) the starting surface contains $0.6 \text{ E-isomers/nm}^2$ and $1.0 \text{ C-isomers/nm}^2$ for the UV (resp. visible) illumination. Symbols correspond to experimental data, and dashed lines to linear fits. Vertical bars mark for each plot the maximum photon dose p^* up to which the cross section remains constant.

Figure 5:

Definition of angles used to calculate J in case the photochromic molecules are constrained in a defined direction of space (see Eq. 2 and text).

Figure 6:

Minimized geometries and relative energies of the isolated amino-fulgimide in its C (a), E (b) and Z (c) forms as calculated by DFT (B3LYP functional, 6-3111+G(d,p) basis set, in vacuum), with the indication of the direction of the electronic transition dipole moment for each isomer (black double arrows) computed by TD-DFT.

Figure 7:

(a) Atomic model of a perfectly grafted Si(111) surface where grey circles are H bonds and black circles feature the anchoring sites of the alkyl monolayer according to a ($3.84 \text{ \AA} \times 6.65 \text{ \AA}$) unit cell (red rectangle). (b) and (c) top and side views of a 3×3 cell with a vacancy at the centre and a C-fulgimide immobilized with an orientation consistent with the experimental results ($\beta = 74^\circ$); The top view is tilted with respect to the surface normal which explains that the red mesh is not rectangular. The side view shows that the fulgimide group is partly embedded in the molecular layer. This configuration is made possible by the presence of a vacancy in the centre of the red mesh. A similar configuration is found for the E form. See text for details.